



ISCH COST Action TD1206



Development and Implementation of European Standards on  
Prevention of Occupational Skin Diseases (StanDerm)

# MAIN OUTCOMES OF WORKING GROUP 4

## SURVEILLANCE, RISK ASSESSMENT AND ALLERGENS

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# MoU #9: . Identification of risk occupations, risk exposures and culprit allergens

- M. Pesonen et al., Contact Dermatitis. 2015;72:154-63.
- W. Uter et al., Contact Dermatitis. 2015;73:69-81.
- K. Warburton et al., Contact Dermatitis (revision to be submitted)

## MoU #10: Identification of trends of contact allergy after e.g. EU wide regulatory interventions

- Baseline paper: M. Pesonen et al.,  
Contact Dermatitis. 2015;72:154-63.
- StanDerm statement on MI regulation

# MoU # 11: Joint open access database containing new workplace allergens and their test modalities

- An extended documentation of occupational hand dermatitis patients has been established which will feed data into future databases on workplace allergens
- Test modalities addressed in review papers (hair cosmetics, rubber, rubber glove)
- Publication of recommendations (free access) or of summaries (epoxy resin systems) via project webiste.

<sup>1)</sup> [strobe-statement.org/](http://strobe-statement.org/)

## MoU # 12: Data which will feed regulation (e.g. REACH) improving risk assessment and management

- StanDerm support for ESSCA activities (occupational allergens, hair cosmetic and rubber allergens)
- Integrating Slovenian and Croatian departments (ESSCA/occupational)
- Review on current practice of management of occupational skin disease across 28 European countries as a basis for improving and harmonising standards of care

# Future perspective

- Further work on identification of new and relevant allergens
- Review on workplace exposure assessment for OSD (M. Bubas)
- Evaluation of extended documentation of hand eczema patients for future implementation as a standard procedure
- Close connections have been established as a basis for future collaboration